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(12) **United States Design Patent** (10) **Patent No.:** **US D962,419 S**  
**Liu** (45) **Date of Patent:** **\*\* Aug. 30, 2022**

(54) **FACE MASK**

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EM 006967634-0005 \* 12/2019

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(\*\*) Term: **15 Years**

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(21) Appl. No.: **29/743,997**

Training Mask (available [online] Jul. 28, 2018) Retrieved Jan. 28, 2022 from Internet URL: <https://www.amazon.com/dp/B07B11ZQN9/> (Year: 2018).\*

(22) Filed: **Jul. 26, 2020**

Reusable Face Mask with Filters (available [online] Jul. 10, 2020) Retrieved Jan. 28, 2022 from Internet URL: <https://www.amazon.com/Reusable-Face-Mask-Filters-Construction/dp/B089LS9WQ1/> (Year: 2020).\*

(51) **LOC (13) Cl.** ..... **29-02**

(52) **U.S. Cl.**

USPC ..... **D24/110.1**; D29/108

(58) **Field of Classification Search**

USPC ..... D24/110, 110.1–110.6; D29/108

CPC . A41D 13/11; A41D 13/1107; A41D 13/1115;

A41D 13/1123; A41D 13/113; A41D

13/1138; A41D 13/1146; A41D 13/1153;

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13/1176; A61M 16/06; A62B 18/00;

A62B 18/02; A62B 18/025; A62B 23/00

See application file for complete search history.

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*Primary Examiner* — Richard Kearney

*Assistant Examiner* — Michael Hoffman

(57) **CLAIM**

The ornamental design for a face mask, as shown and described.

(56) **References Cited**

**DESCRIPTION**

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FIG. 1 is a perspective view of a face mask showing my new design;

FIG. 2 is a front elevational view thereof;

FIG. 3 is a rear elevational view thereof;

FIG. 4 is a left side elevational view thereof;

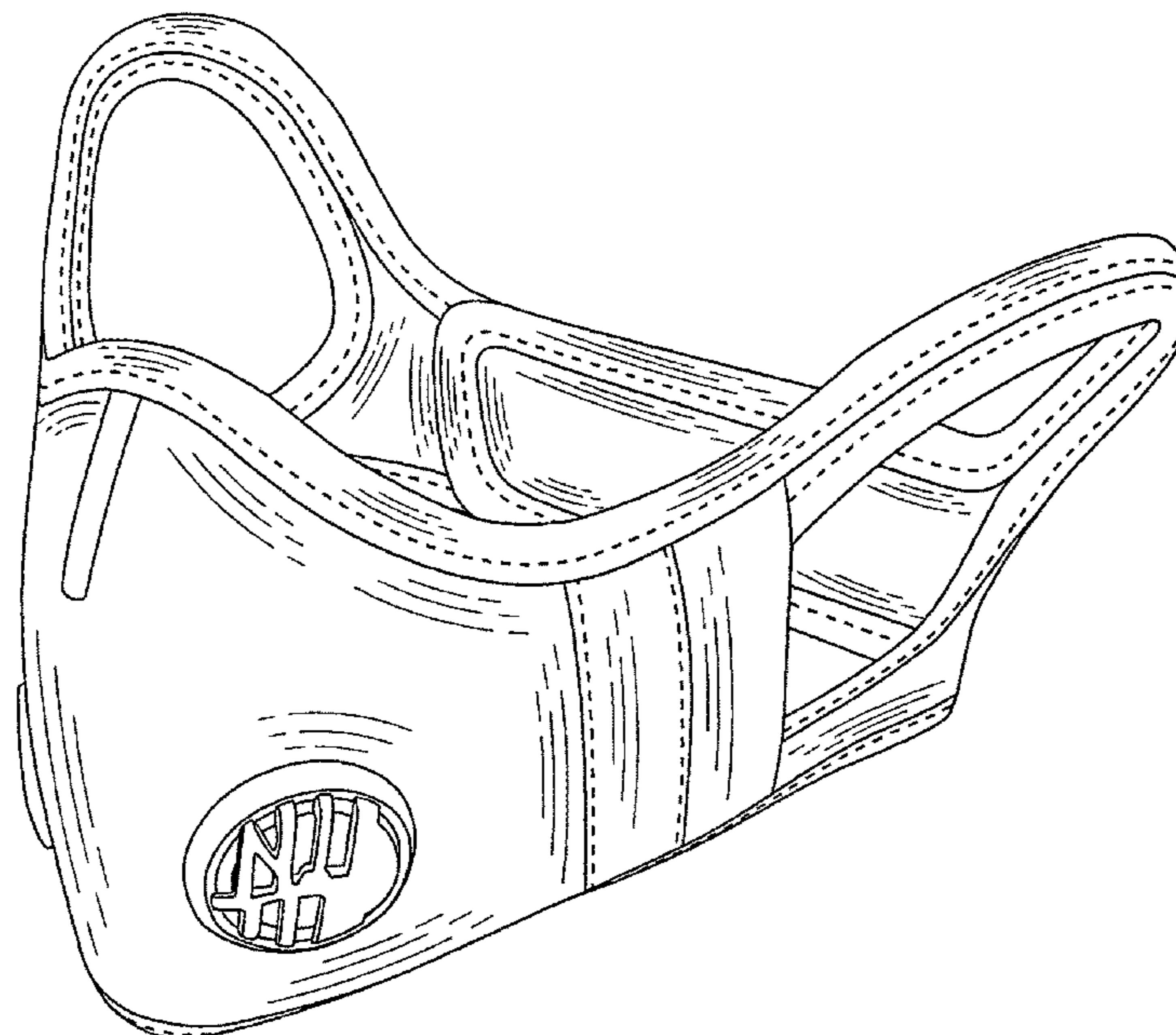
FIG. 5 is a right side elevational view thereof;

FIG. 6 is a top plan view thereof; and,

FIG. 7 is a bottom plan view thereof.

The broken lines shown in the drawings depict stitching which forms part of the claimed design.

**1 Claim, 7 Drawing Sheets**



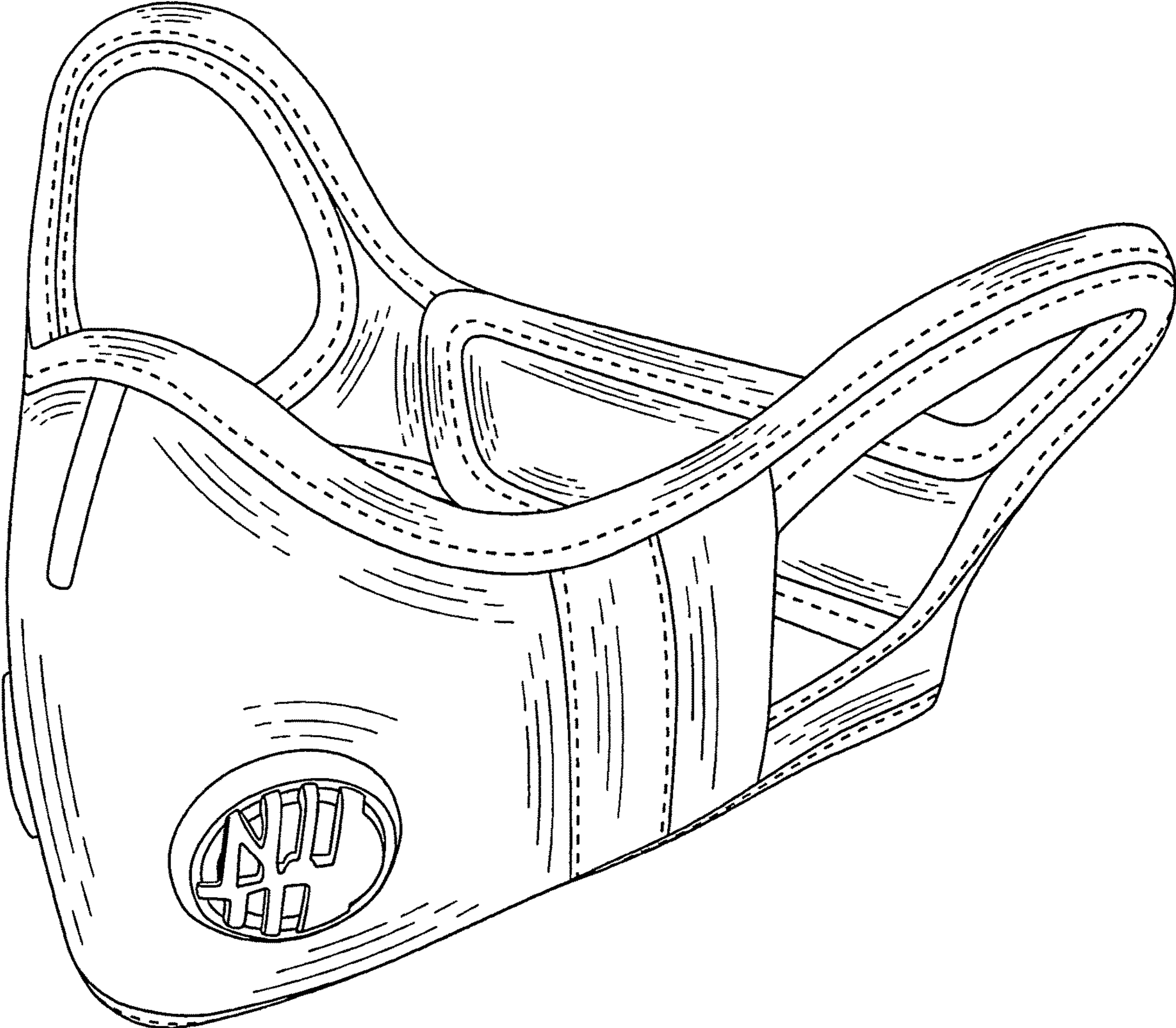


FIG. 1

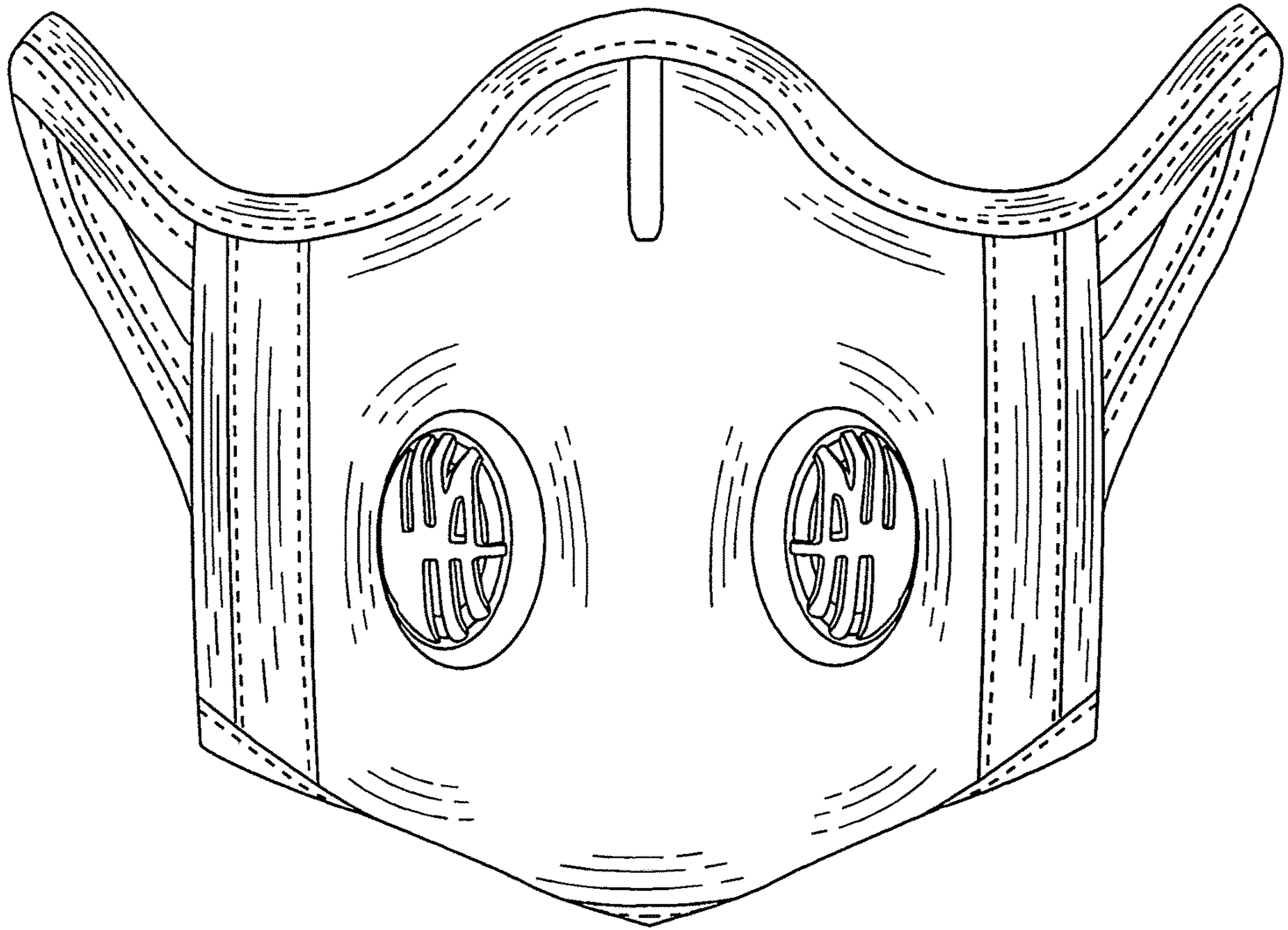


FIG. 2

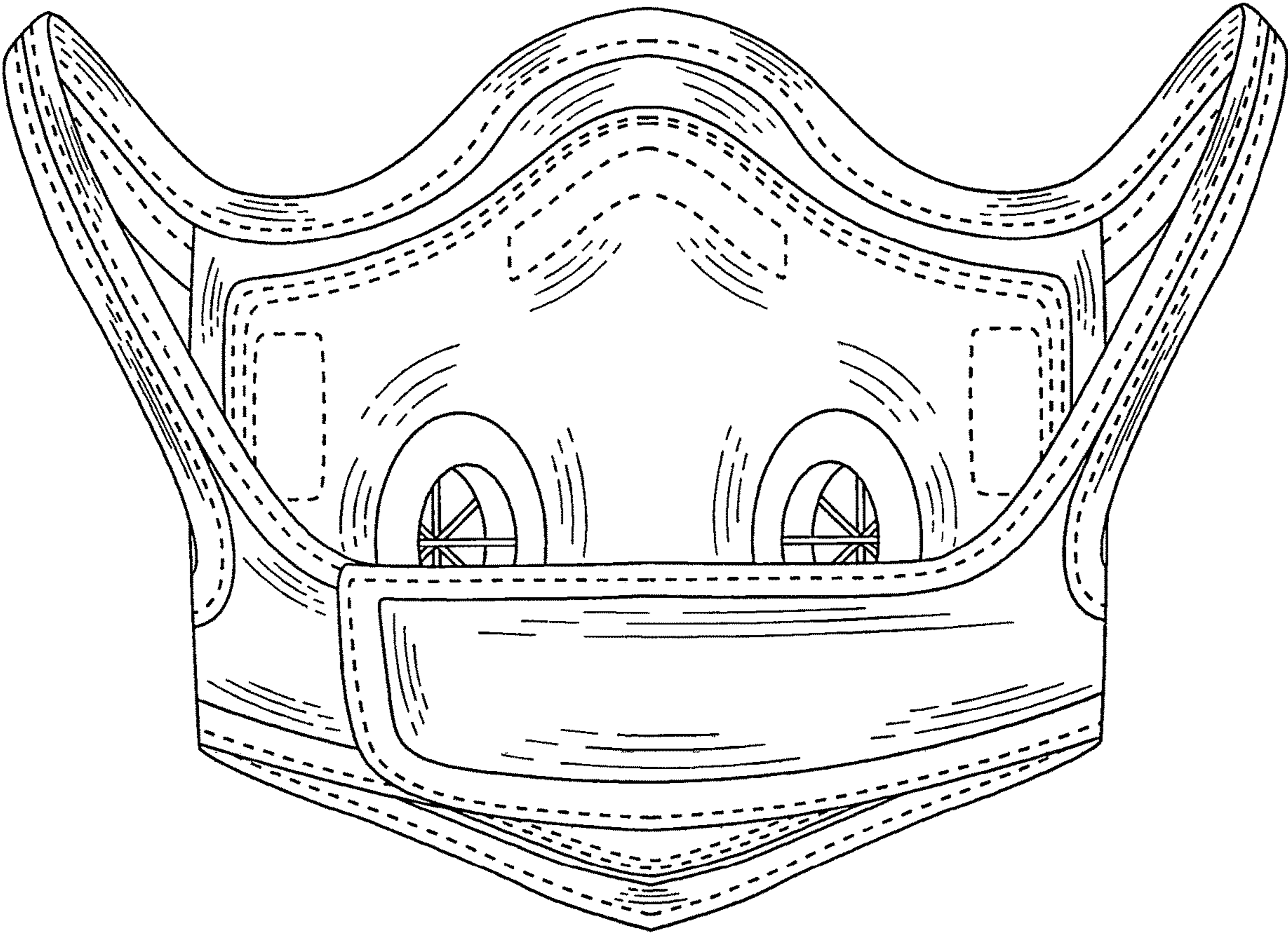


FIG. 3

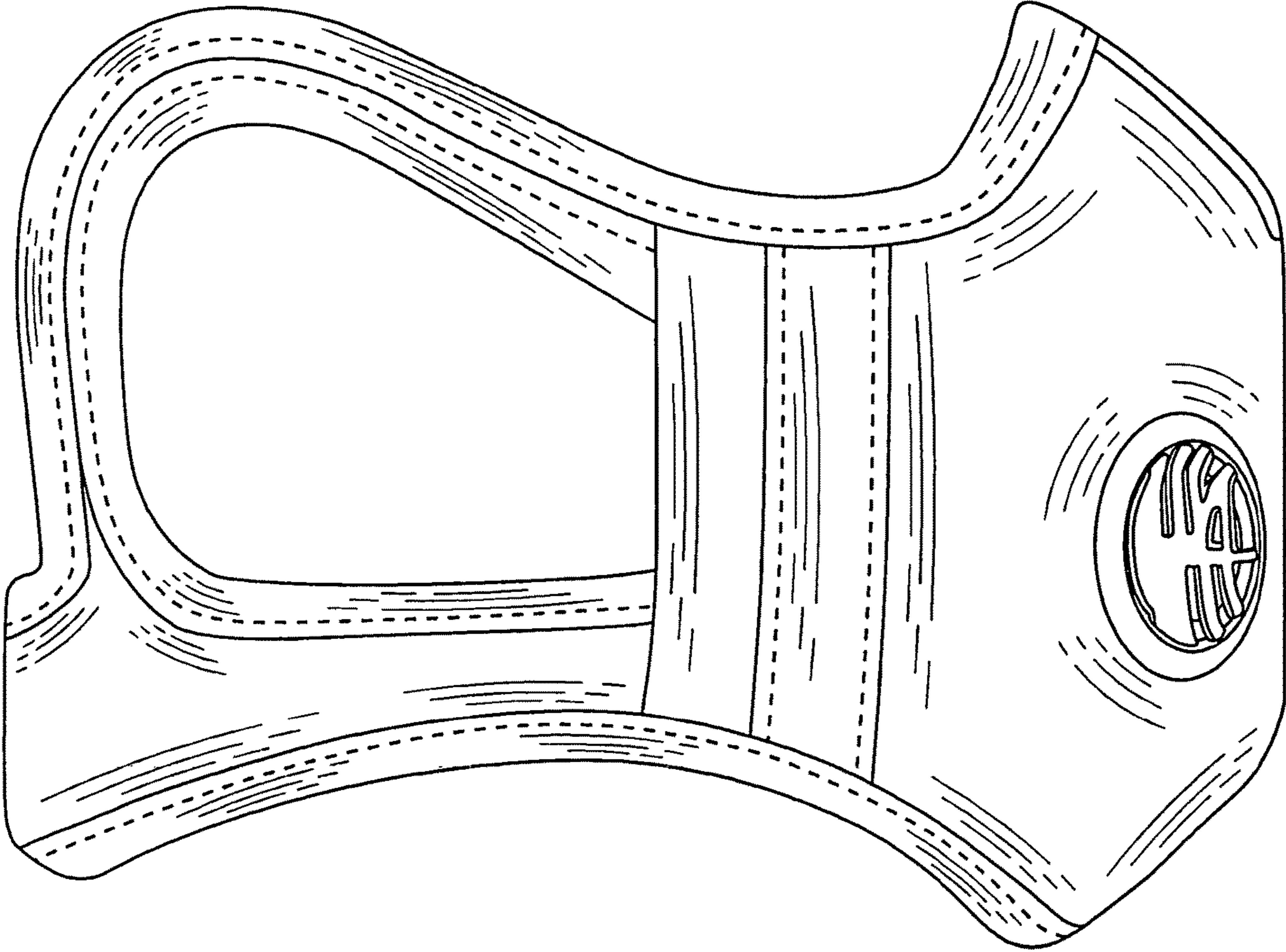


FIG. 4

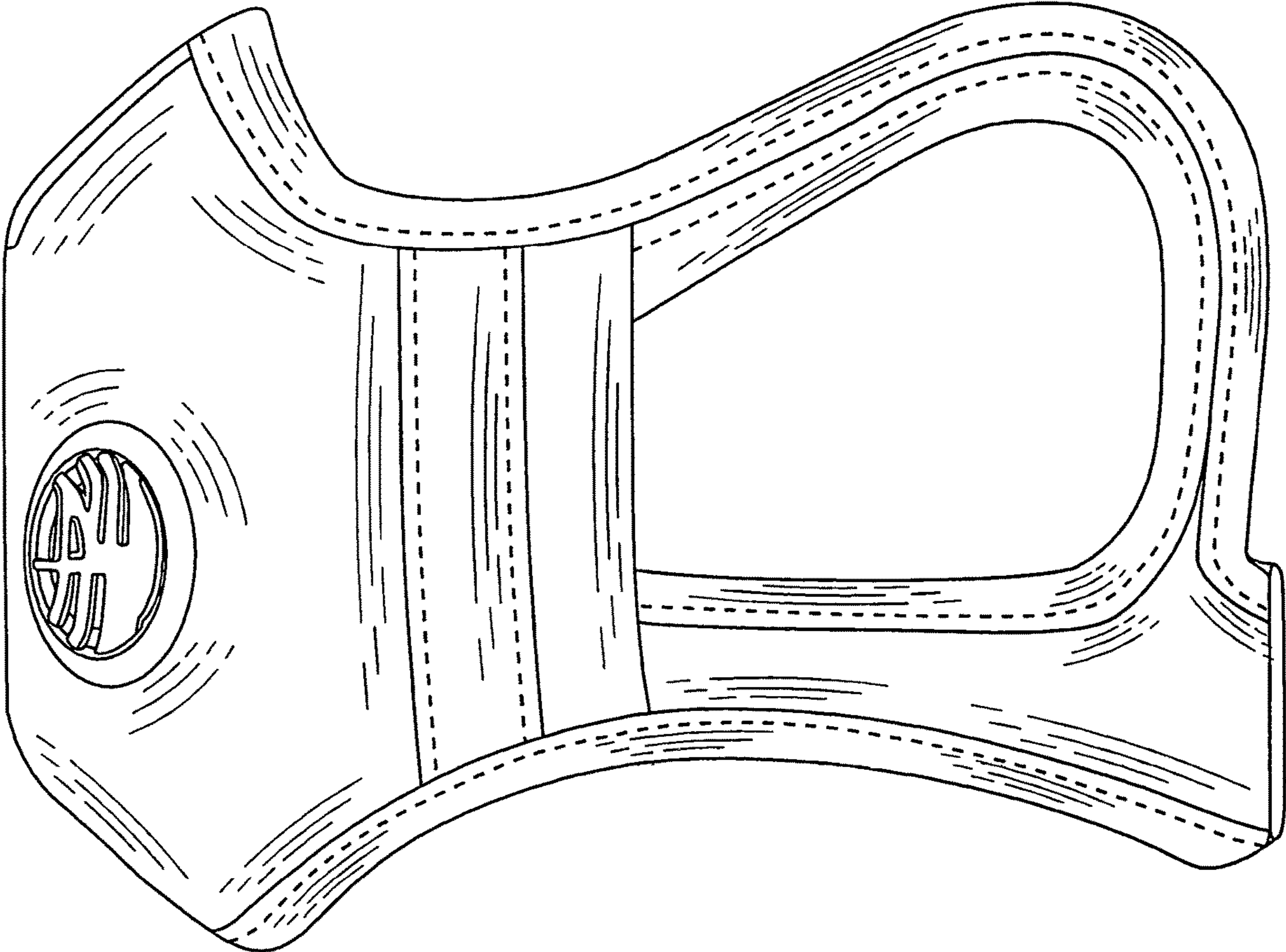


FIG. 5

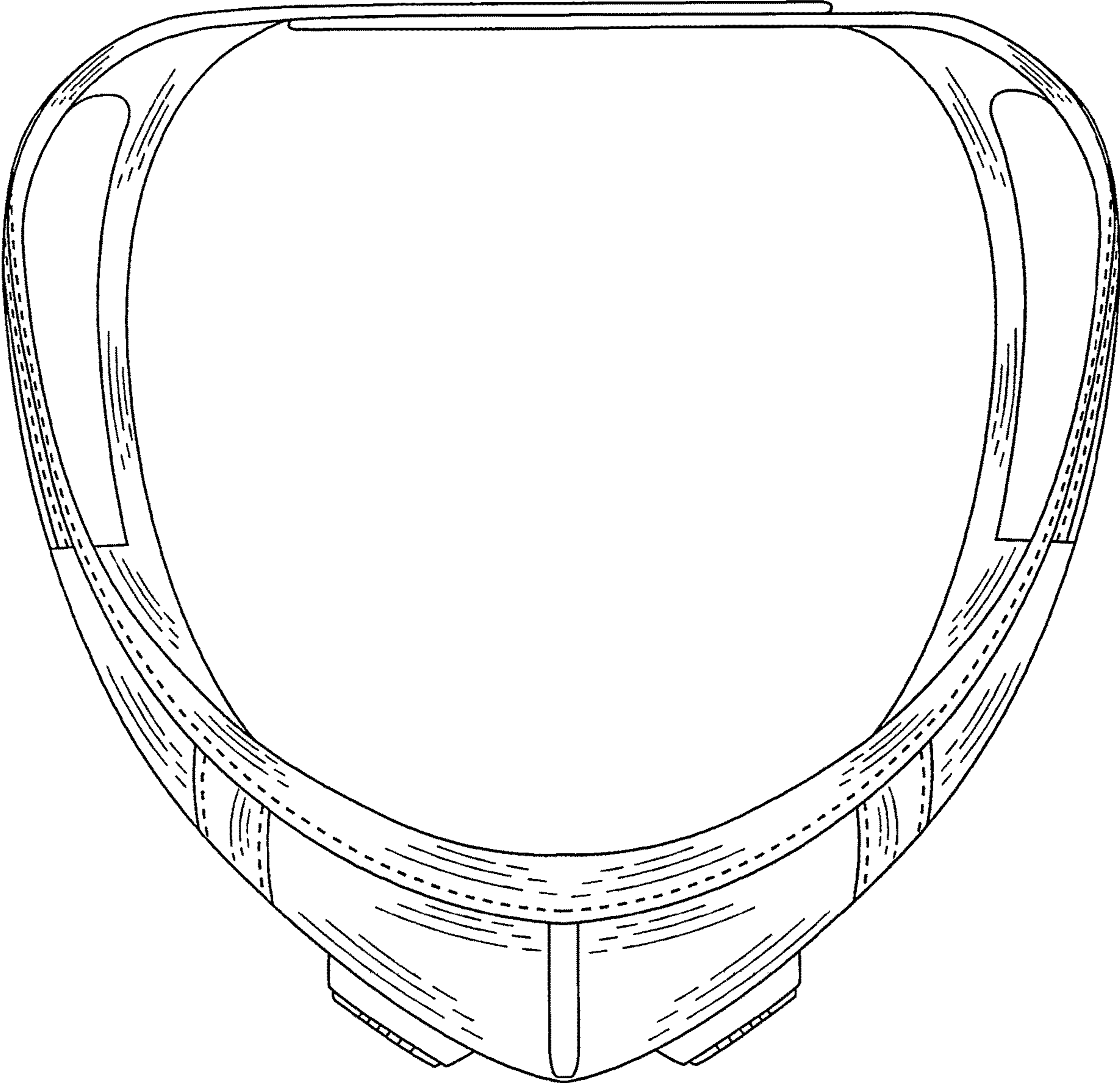


FIG. 6

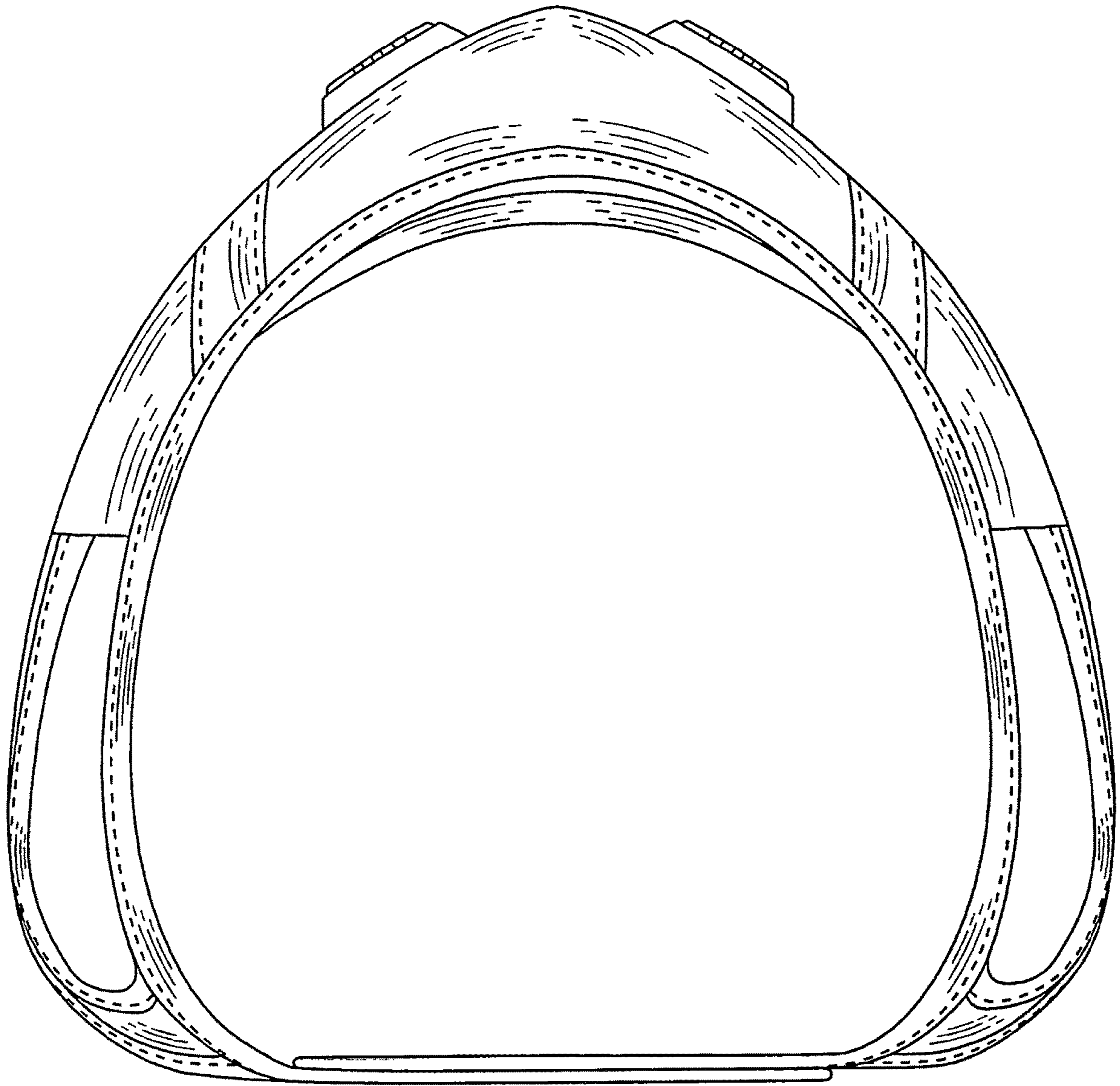


FIG. 7